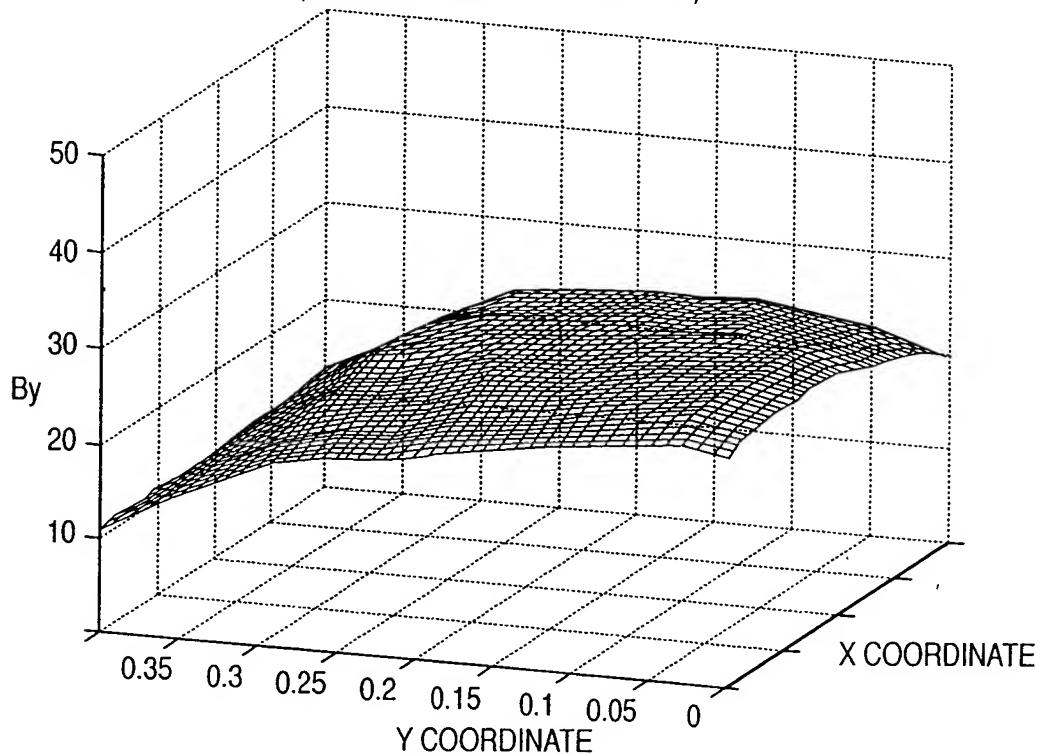


F I G. 10A

DISTRIBUTION OF MAGNETIC FLUX DENSITY B_y IN NEIGHBORHOOD OF SUBSTRATE
(ABSOLUTE VALUE INDICATION)

**F I G. 10B**

DISTRIBUTION OF MAGNETIC FLUX DENSITY B_y IN NEIGHBORHOOD OF SUBSTRATE
(ABSOLUTE VALUE INDICATION)

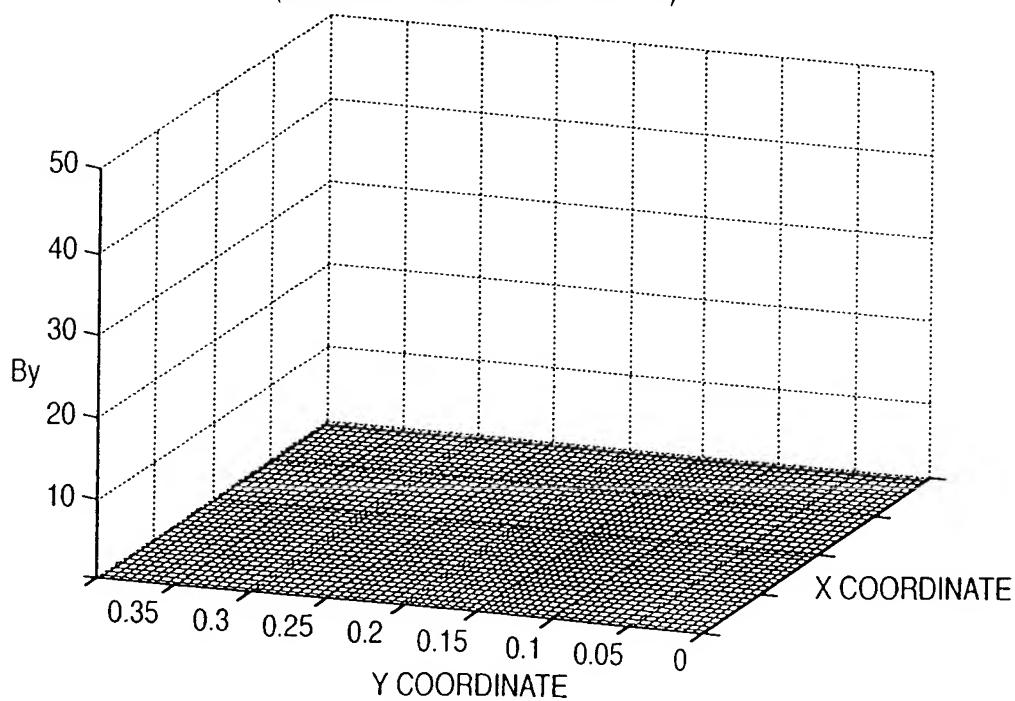


FIG. 1

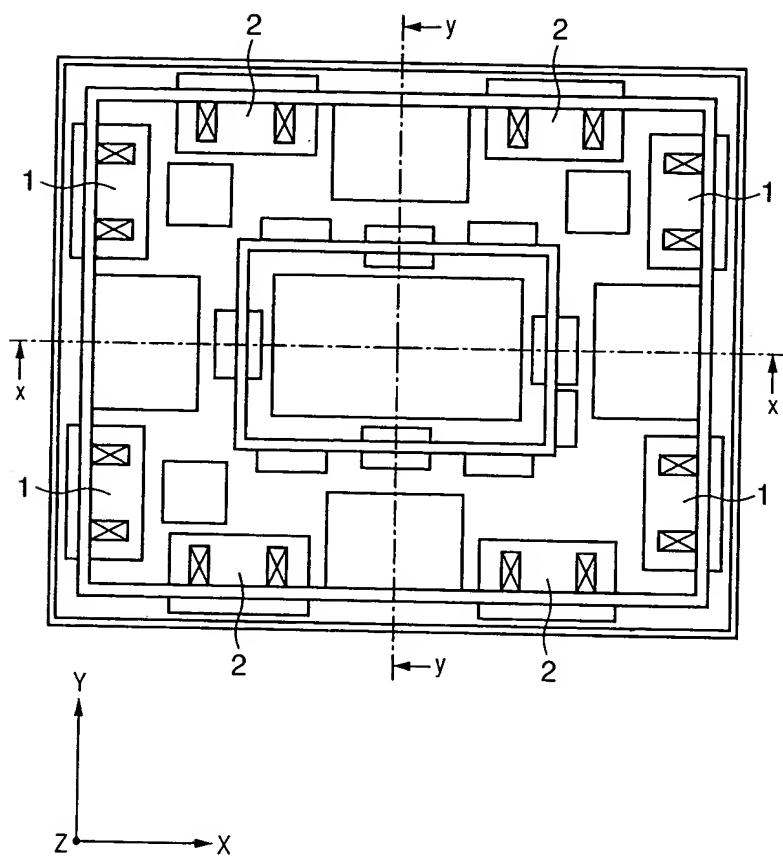
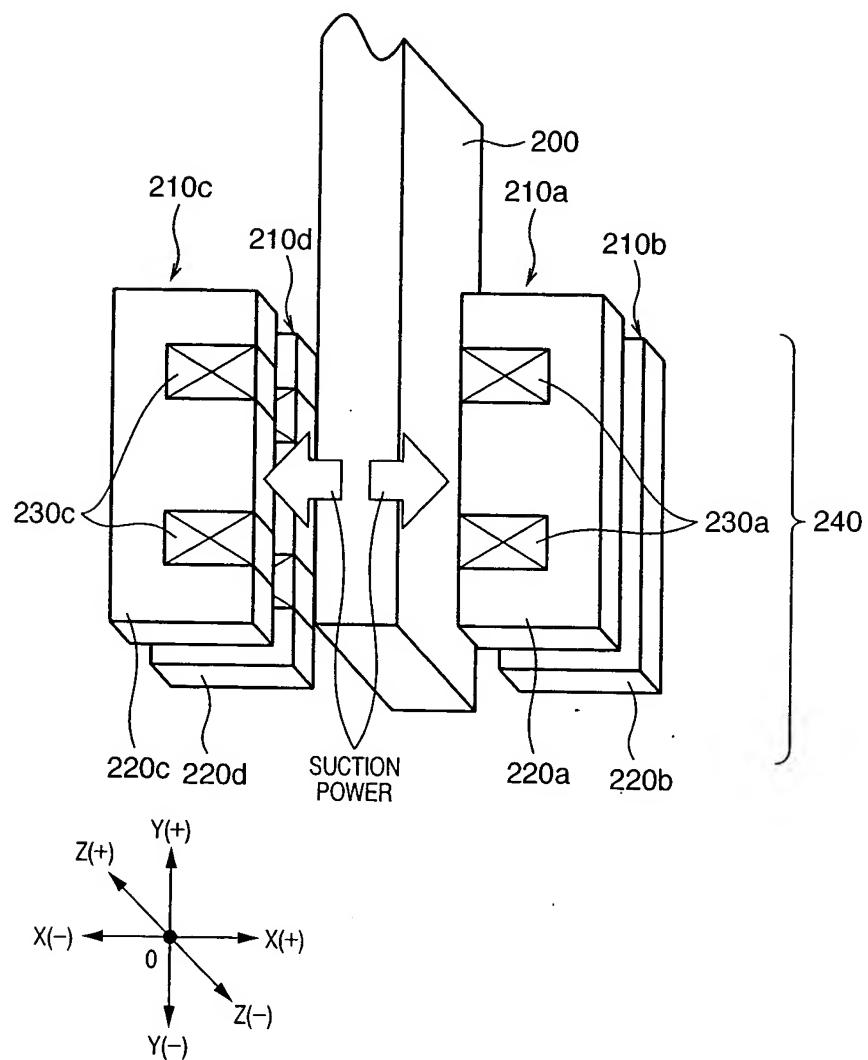


FIG. 2A



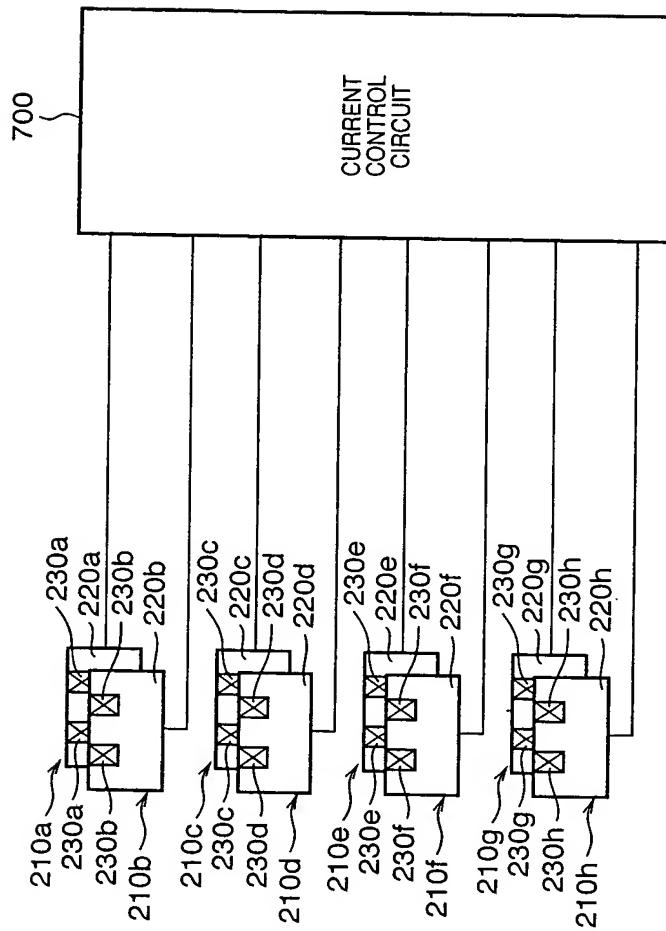
F I G. 2B

FIG. 3A

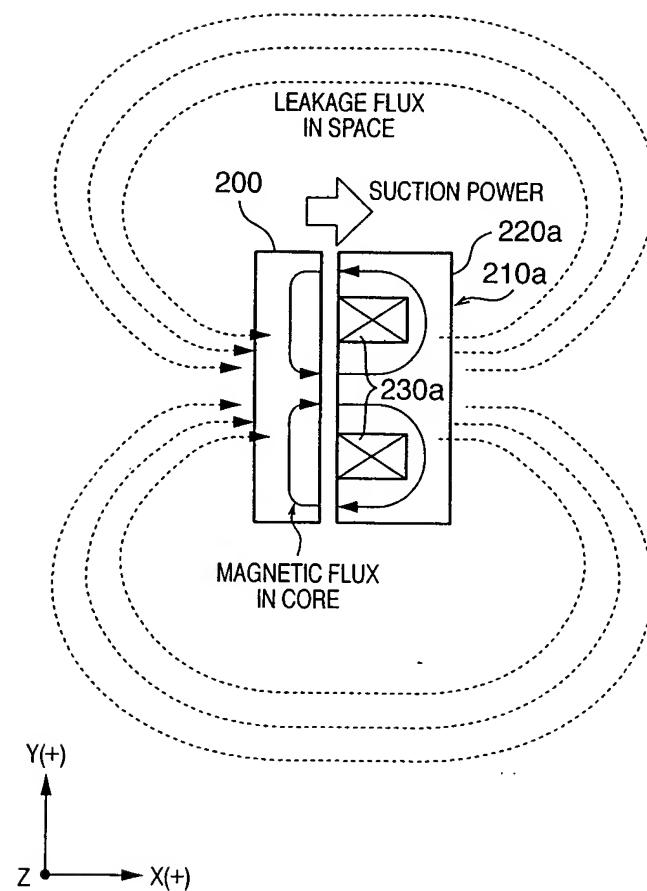
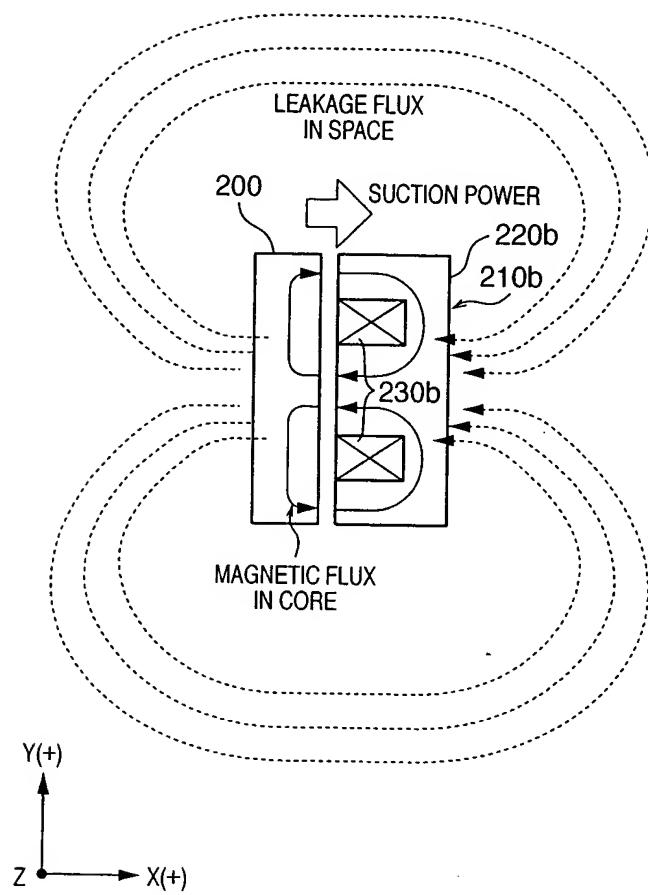


FIG. 3B



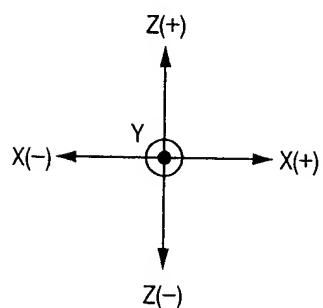
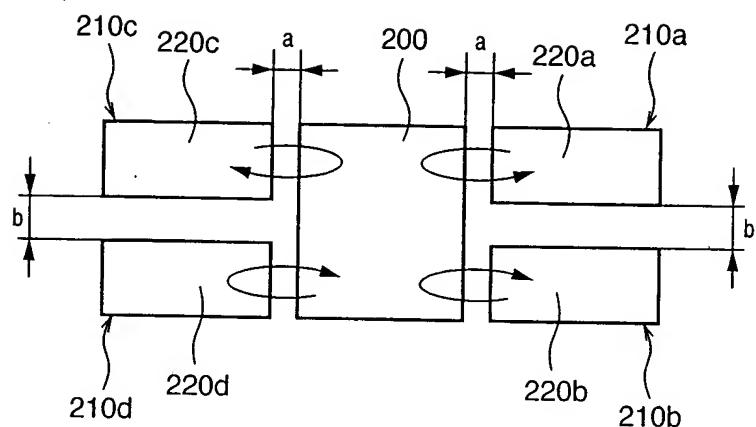
F I G. 3C

FIG. 4

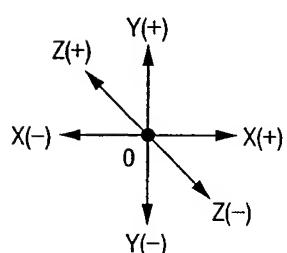
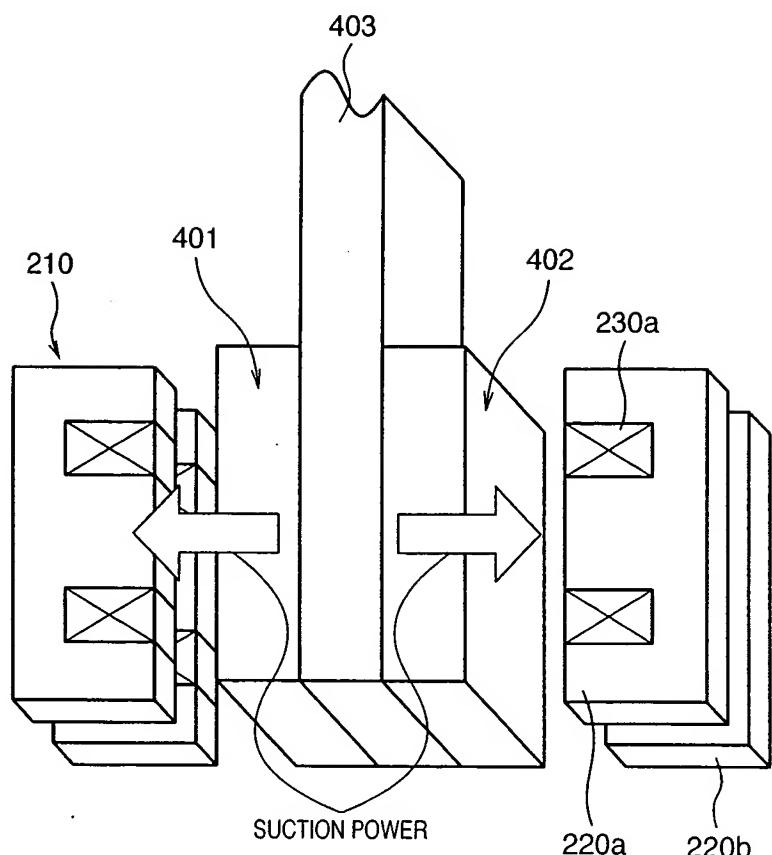


FIG. 5

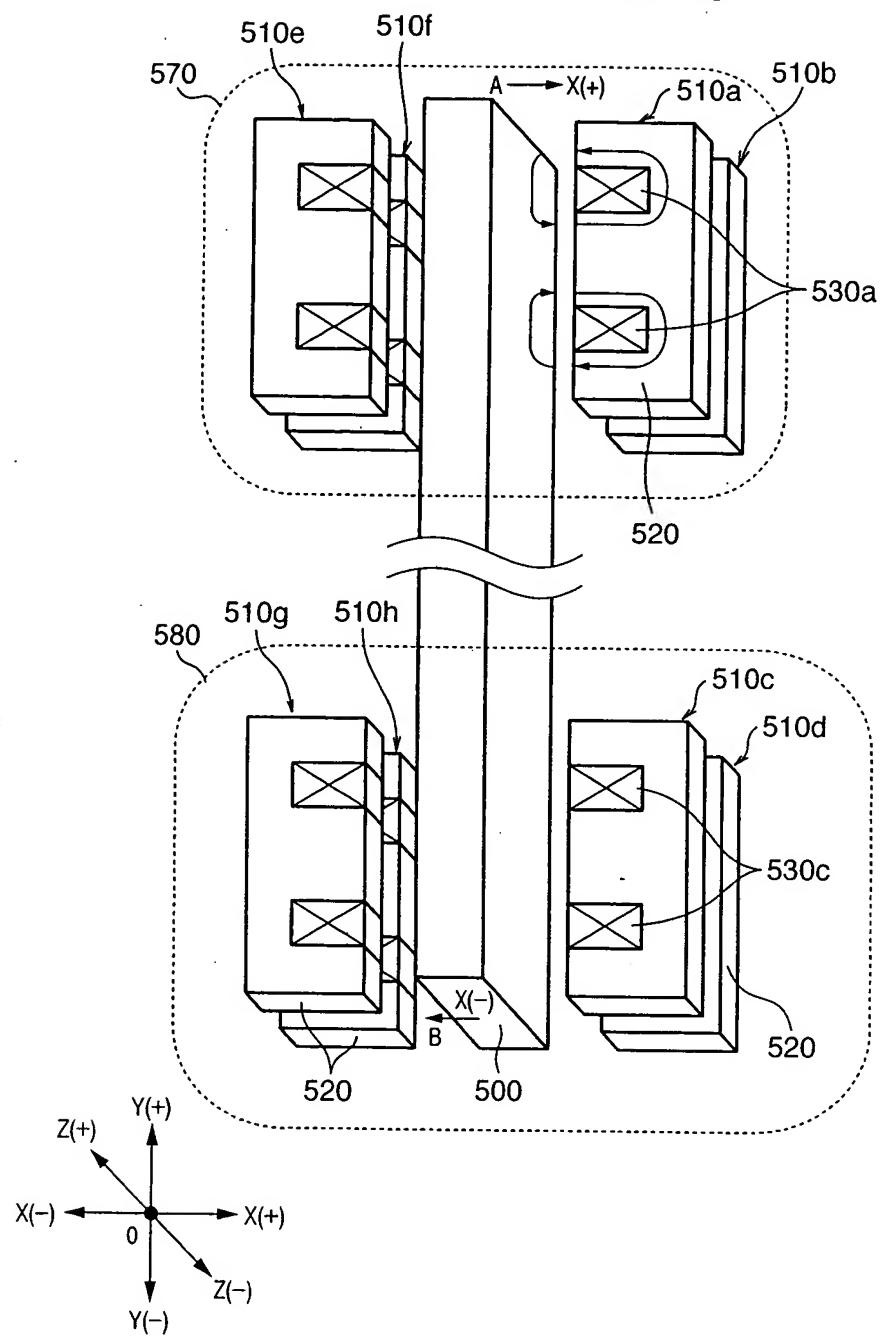


FIG. 6

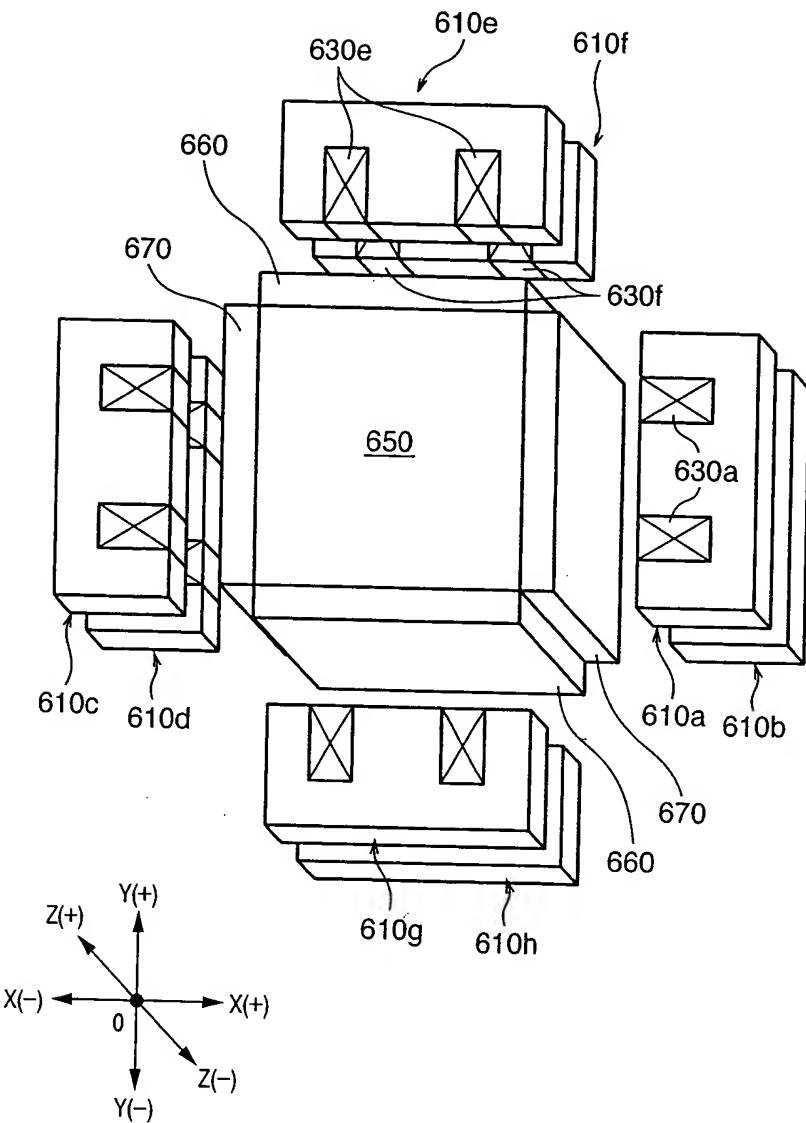
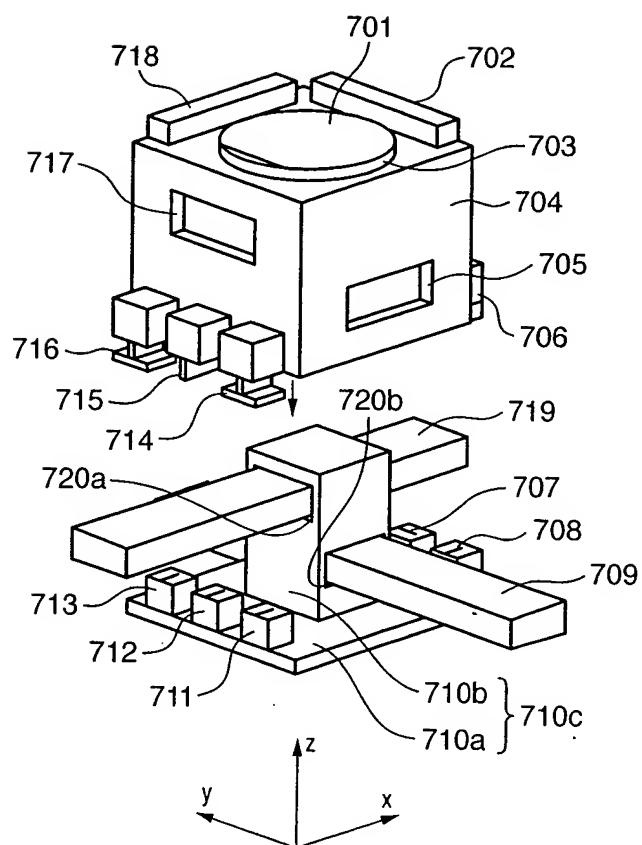


FIG. 7A



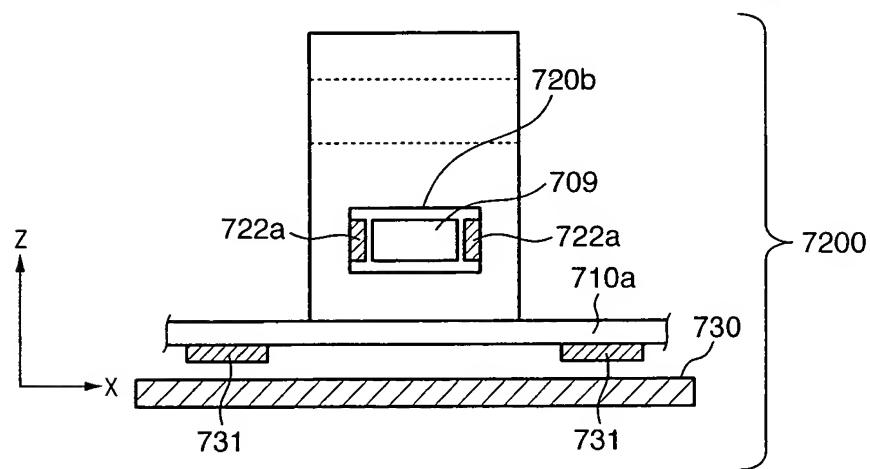
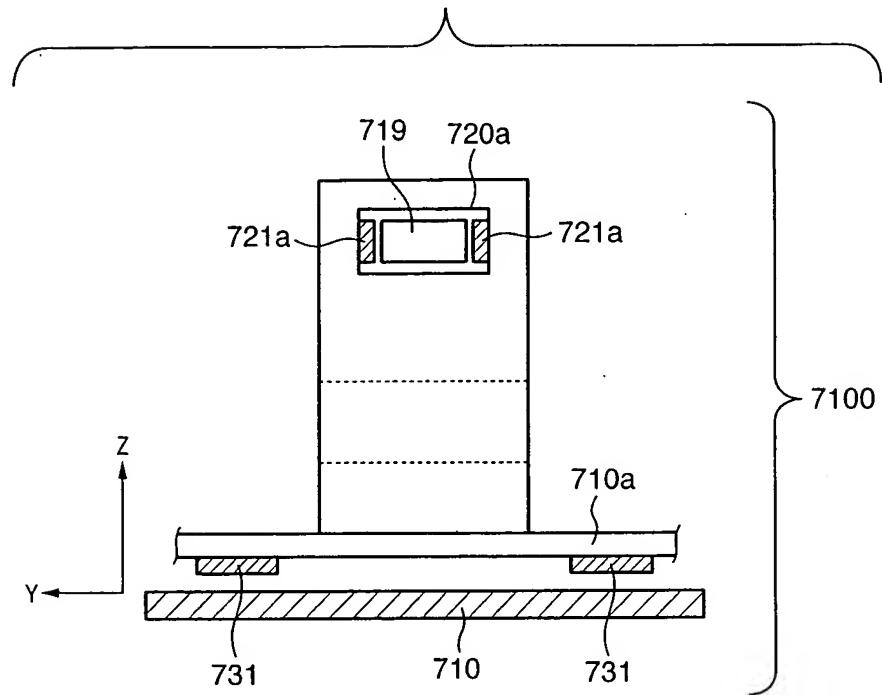
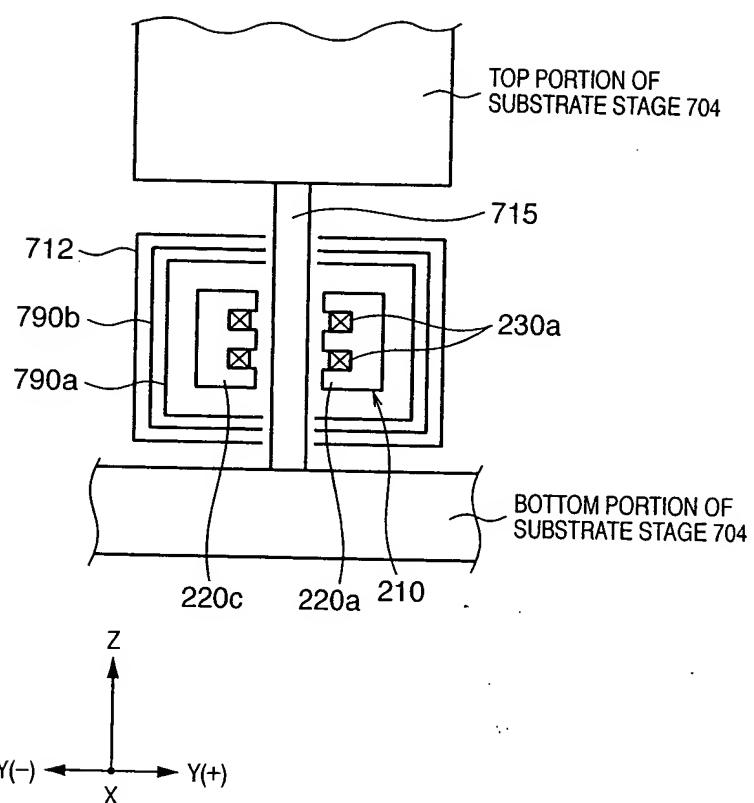
F I G. 7B

FIG. 7C



17/20
F I G. 11B

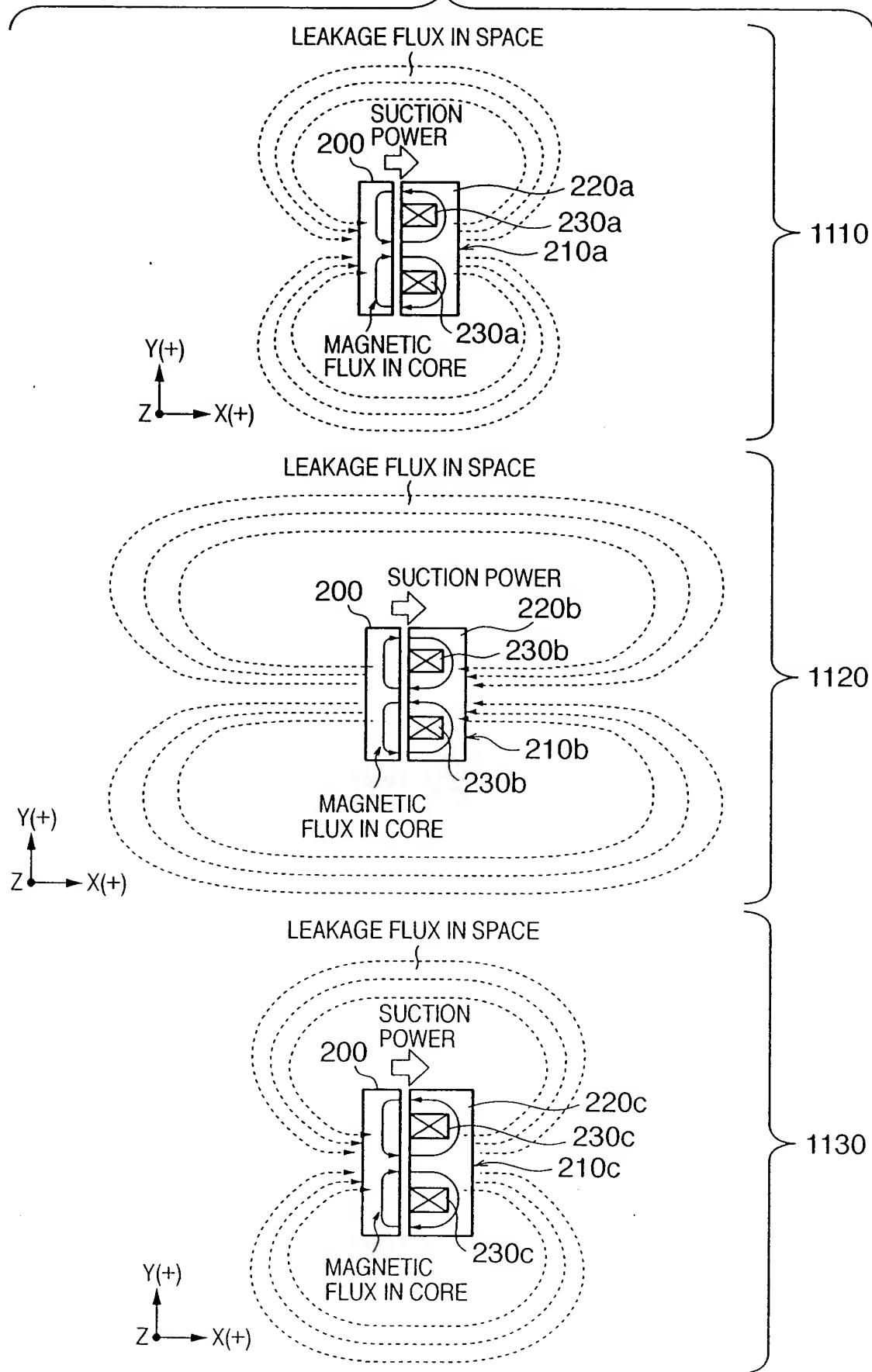
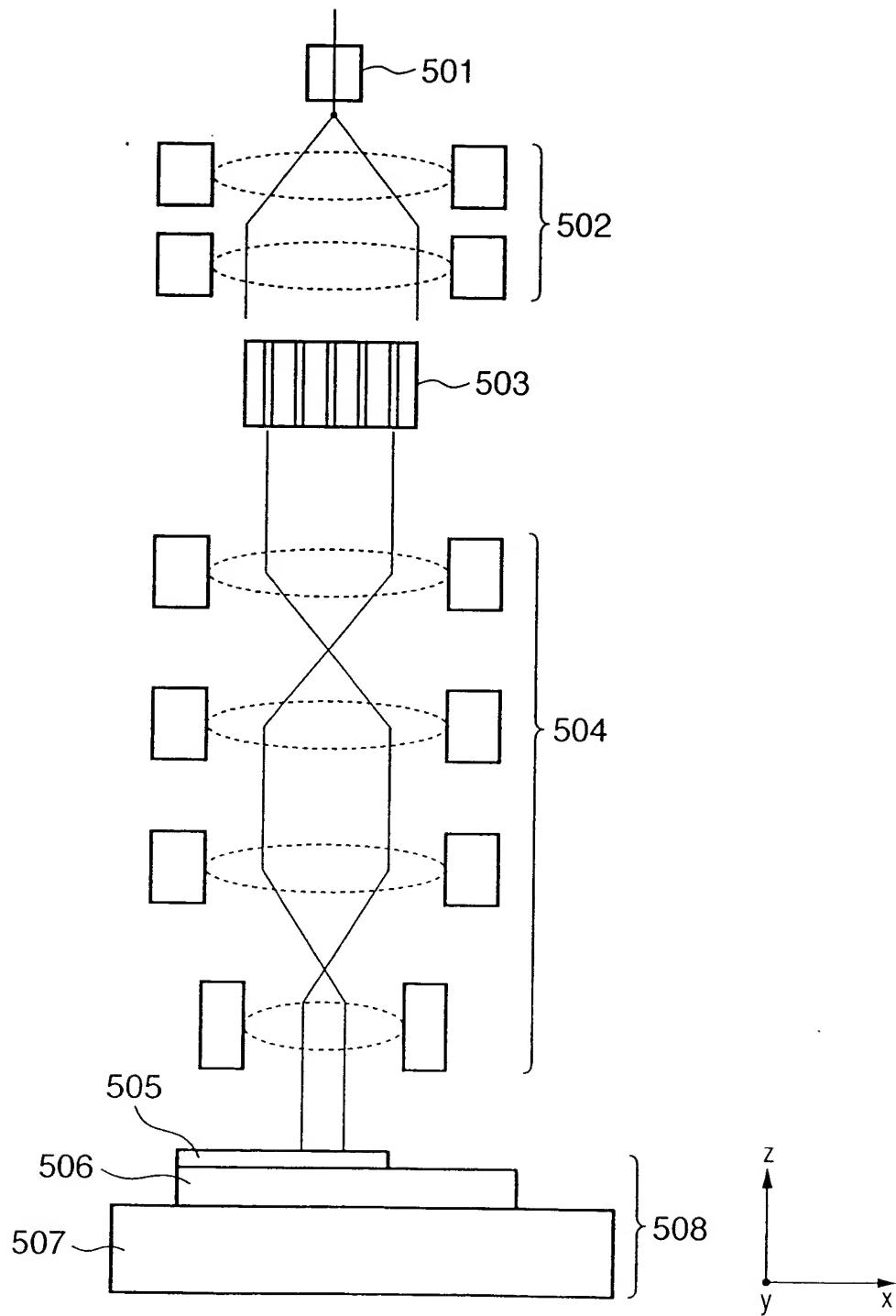
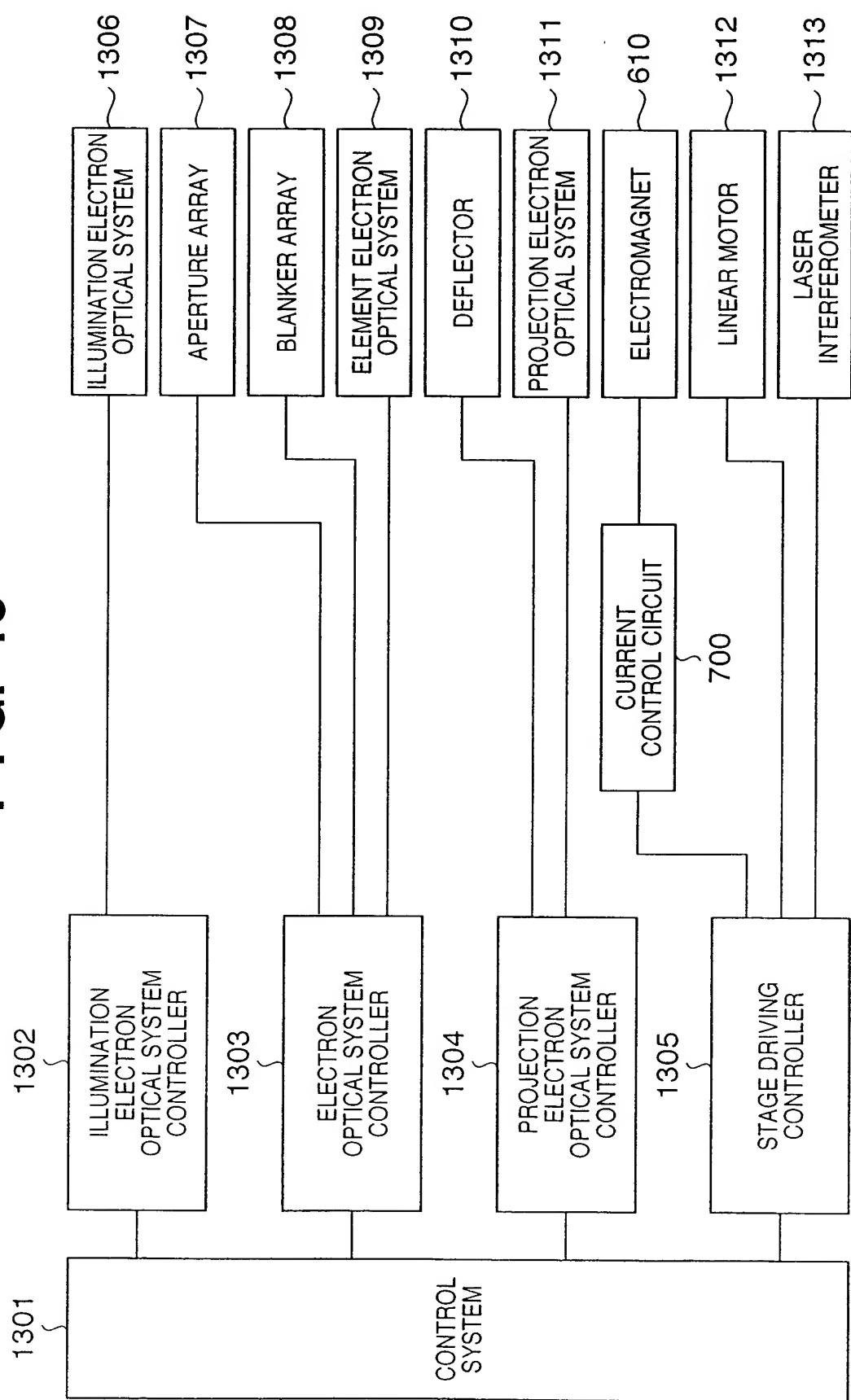
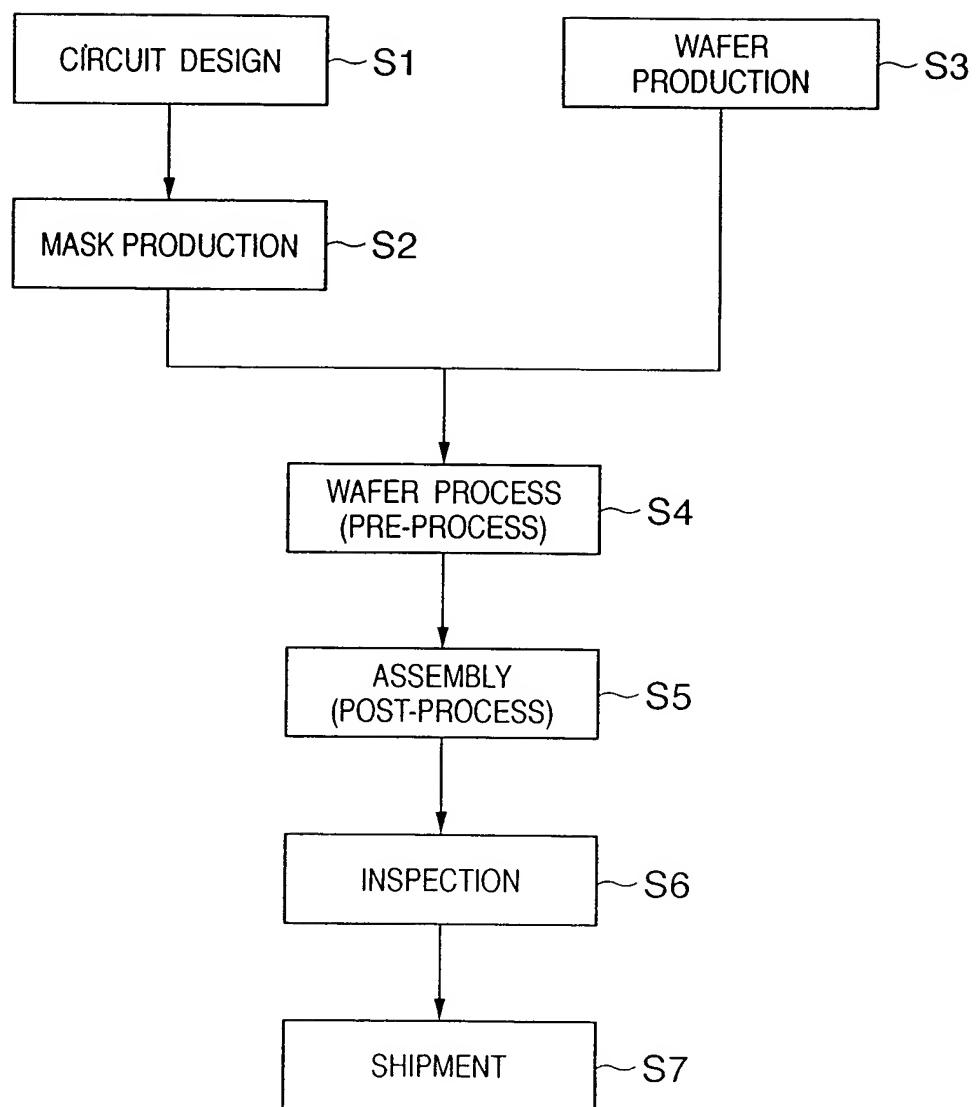


FIG. 12



F I G. 13



F I G. 14

SEMICONDUCTOR DEVICE MANUFACTURING FLOW

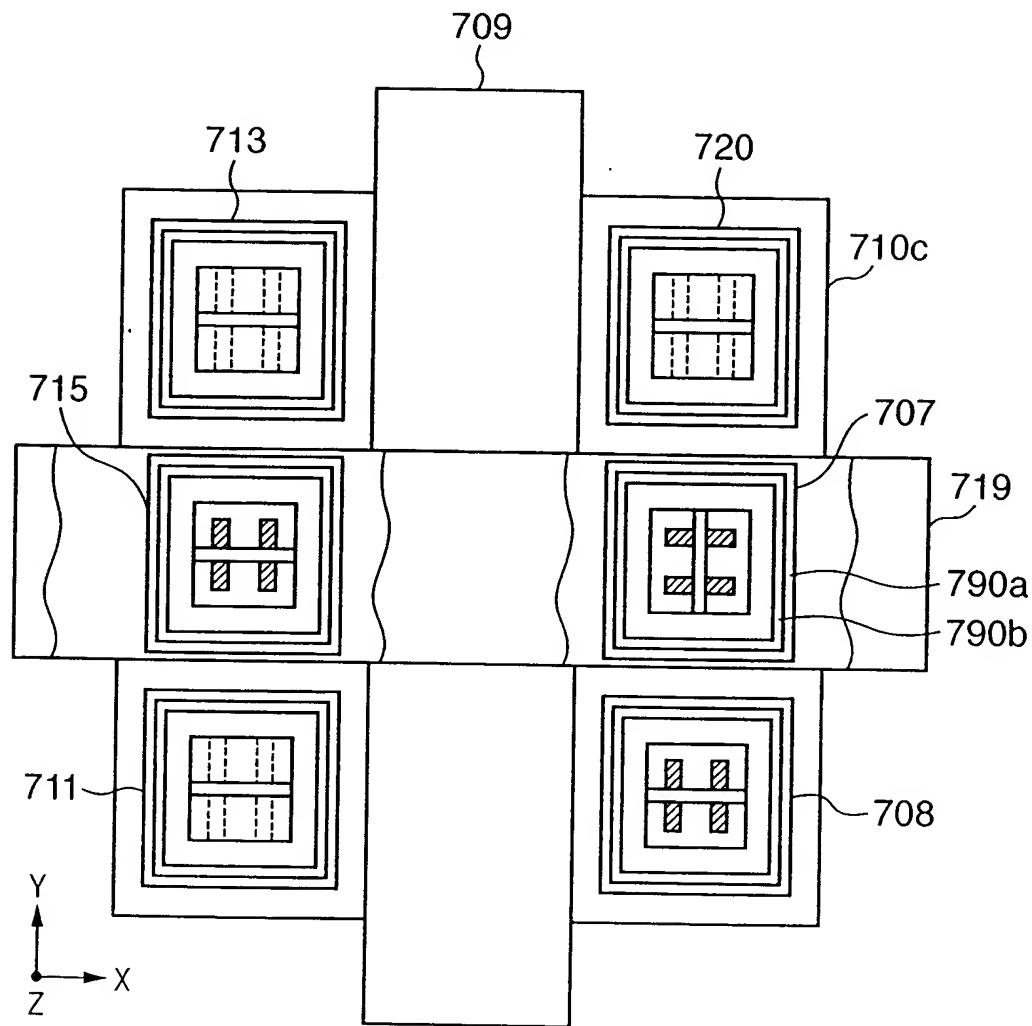
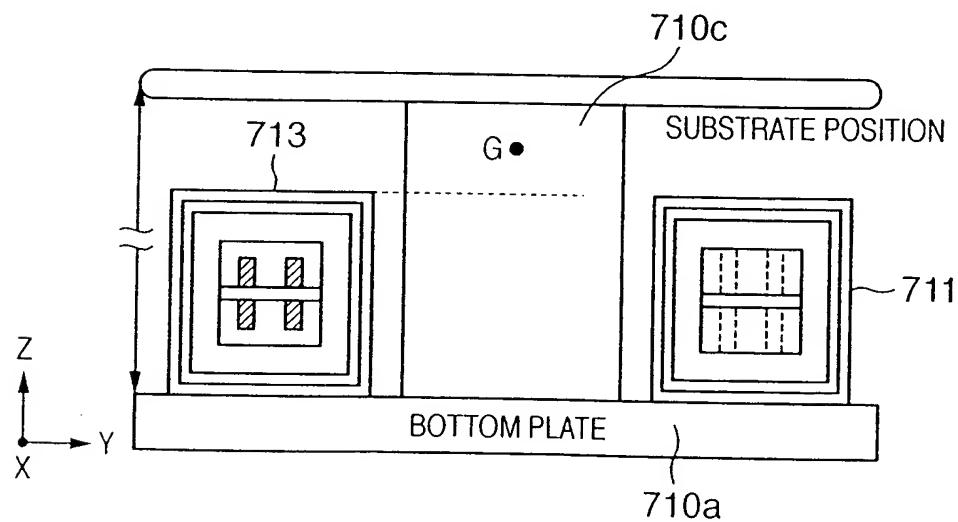
F I G. 9A**F I G. 9B**

FIG. 11A

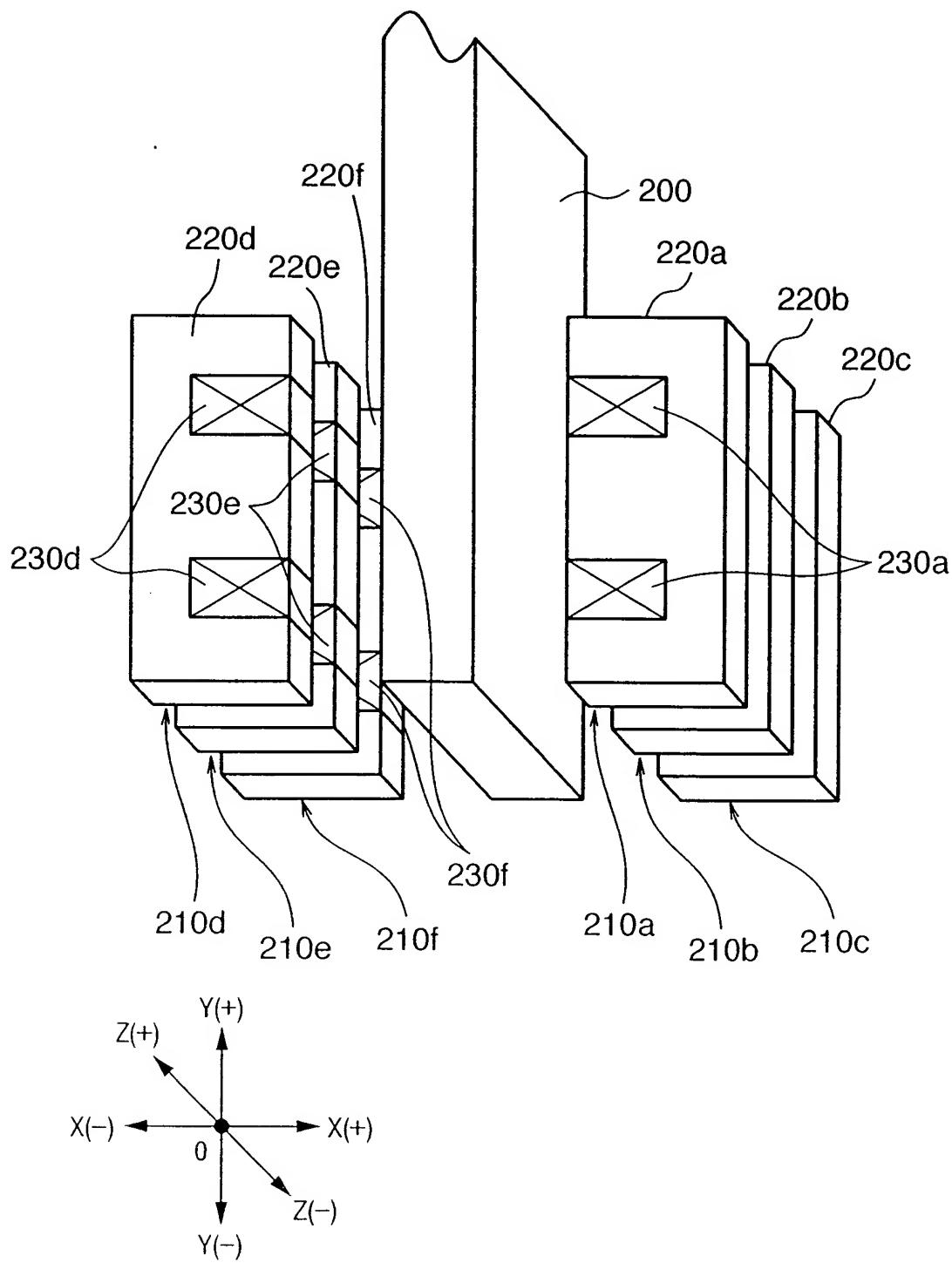


FIG. 8